

Thermodynamic state functions

$$U^\sigma = U - U_g - U_{szil}$$

$$H^\sigma = H - H_g - H_{szil}$$

$$S^\sigma = S - S_g - S_{szil}$$

$$F^\sigma = F - F_g - F_{szil} \quad F = U - TS$$

Thermodynamic condition of the adsorption equilibrium

Adsorption: $dn^\sigma > 0$ $n^\sigma = n - n^g$

$$\left(\frac{\partial F}{\partial n^\sigma}\right)_{T,V,A_s,n} = 0 \quad F^\sigma = F - F^g - F^s$$

$$\left(\frac{\partial F}{\partial n^\sigma}\right)_{T,V,A_s,n} = \left(\frac{\partial F^\sigma}{\partial n^\sigma}\right)_{T,A_s} + \left(\frac{\partial F^g}{\partial n^\sigma}\right)_{T,V} + \left(\frac{\partial F^s}{\partial n^\sigma}\right)_{T,A_s} = 0$$

In a closed system: $dn = dn^\sigma + dn^g = 0$ 0 (physisorption)

$$\left(\frac{\partial F^\sigma}{\partial n^\sigma}\right)_{T,A_s} = -\left(\frac{\partial F^g}{\partial n^\sigma}\right)_{T,V} = +\left(\frac{\partial F^g}{\partial n^g}\right)_{T,V}$$

$$\mu^\sigma = \mu^g \quad \text{Chemical potential}$$

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Physisorption vs Chemisorption

PHYSISORPTION	CHEMISORPTION
WEAK, LONG RANGE BONDING Van der Waals interactions	STRONG, SHORT RANGE BONDING Primary chemical bond involved.
NOT SURFACE SPECIFIC Physisorption takes place between all molecules on any surface providing the temperature is low enough.	SURFACE SPECIFIC E.g. Chemisorption of hydrogen takes place on transition metals but not on gold or mercury.
$\Delta H_{\text{ads}} = 5 \dots 50 \text{ kJ mol}^{-1}$	$\Delta H_{\text{ads}} = 50 \dots 500 \text{ kJ mol}^{-1}$
Non activated with equilibrium achieved relatively quickly. Increasing temperature always reduces surface coverage.	Can be activated, in which case equilibrium can be slow and increasing temperature can favour adsorption.
No surface reactions.	Surface reactions may take place:- Dissociation, reconstruction, catalysis.
MULTILAYER ADSORPTION	MONOLAYER ADSORPTION

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Electron transfer

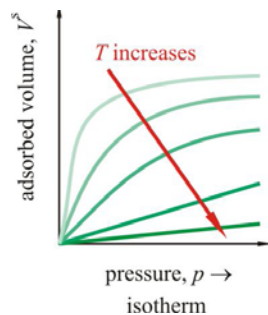
Adsorption at S/G interfaces

Always occurs when a solid surface is exposed to a gas phase

Separation techniques
 Environmental processes
 Protection of the environment
 Gas separation and purification
 Analytical chemistry
 Materials science
 Characterisation of solid surfaces

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Quantitative description of S/G adsorption



Adsorption occurs on the whole accessible surface

Most often measured:

$$m^s, n^s, V^s_{(p,T)} = f(p)_T \quad n^s = f(p)_T$$

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Steps for Measurement

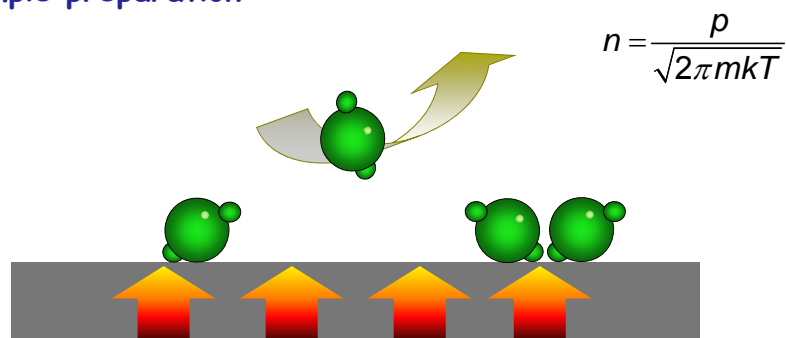
1. Sample Preparation

2. Data Collection
(Adsorption Analysis)

3. Interpretation

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1. Sample preparation



Ambient air, 25 °C
 10^{15} surface atom/cm²
 $\rightarrow \sim 10^8$ collision/s

3×10^{23} collision/cm²s

- removal of surface moisture, pollution
- vacuum
- temperature - heat resistancy of the materials
- sample size

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Pure solid surface

$$n = \frac{p}{\sqrt{2\pi mkT}}$$

Ambient pressure, 25 °C 3×10²³ collision/cm²s

10¹⁵ surface atom/cm²

→ ~ 10⁸ collision/s

~ 10⁻⁸ ambient

4×10¹⁴ cm⁻²s⁻¹

1 collision within 3 s

~ 10⁻¹² ambient

10¹¹ cm⁻²s⁻¹

~ 10⁻¹⁴ ambient

10⁹ cm⁻²s⁻¹

1 collision within 10³-10⁵ s

The vacuum as medium

10⁻⁴ Pa

1 collision/ ~ 1 m free path

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2. Data collection methods

static methods: - **VOLUMETRIC**

- **gravimetric**

Automatic commercial instruments



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Vacuum

Helium

Adsorbate

Sample cell

Outgassing station

Analysis station

P_0

- Surface contamination is removed by application of:
 - Temperature
 - Flowing gas (helium or nitrogen)
 - Vacuum
- Backfill can be done using helium or adsorbate gas.
- According to IUPAC standards, porous materials should be outgassed for **at least 16 hours**.

Mass of the sample 44

